



PATENT

Customer No. 22,852

Attorney Docket No. 07553.0008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
KOSHIMIZU et al.) Group Art Unit: 1765
)
Application No.: 09/665,940) Examiner: L. T. Umez Eronini
)
Filed: September 21, 2000)
)
For: PLASMA PROCESSING)
APPARATUS AND PLASMA)
PROCESSING METHOD)

Commissioner for Patents
Washington, DC 20231

Sir:

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JAN 02 2003
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AMENDMENT

In reply to the Office Action dated August 30, 2002, the period for reply having been extended for one month by a request for extension and fee payment filed concurrently herewith, please amend the application as follows:

IN THE CLAIMS:

Please cancel claims 12-22 without prejudice or disclaimer and add new claims 23-32, as follows:

--23. (New) A plasma processing method, comprising:

a step in which a workpiece is placed at a mounting surface of an electrode provided inside a plasma processing chamber;

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